



PATENT  
5310-03000

Fee Only

Application No.: 09/744,877 §  
Confirmation No.: 8711 §  
Filing Date: January 29, 2001 §  
Inventors: Halimaoui et al. §  
Title: PROCESS FOR FORMING  
AN OXIDE LAYER OF  
NON-UNIFORM  
THICKNESS ON THE  
SURFACE OF A SILICON  
SUBSTRATE §  
Examiner: Novacek, Christy L. §  
Art Unit: 2822 §  
Atty. Dkt. No: 5310-03000 §

CERTIFICATE OF MAILING  
UNDER 37 C.F.R. §1.8  
DATE OF DEPOSIT: 1/21/04  
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**REQUEST FOR CONTINUED EXAMINATION  
REQUEST TRANSMITTAL**

(under 37 CFR § 1.114)

This is a request for continued examination under 37 C.F.R. § 1.114 of application number 09/744,877, filed on January 29, 2001, entitled PROCESS FOR FORMING AN OXIDE LAYER OF NON-UNIFORM THICKNESS ON THE SURFACE OF A SILICON SUBSTRATE.

Inventor(s):	Aomar Halimaoui, André Grouillet		
Examiner:	Novacek, Christy L.	Group/Art Unit:	2822
Assignee:	France Telecom	Recorded at	Reel 011545, Frame 0952
Correspondence Address in Prior Application:	Eric B. Meyertons Conley, Rose, & Tayon, P.C. P.O. Box 398 Austin, Texas 78767-0398		

**Application Elements**

1. ☒ Filing Fee  
☒ A Fee Authorization Form authorizing a deposit account debit for the RCE fee (\$770.00) required under 37 C.F.R. § 1.17(e) is enclosed.
2. ☒ Information Disclosure Statement (IDS)  
☒ Copies of IDS Citations  
☒ Form(s) PTO-1449 (1 page)
3. Amendments  
☒ An amendment is enclosed.  
☐ Enter the unentered amendment previously filed on \_\_\_\_\_ under 37 C.F.R. § 1.116.  
☐ Please consider the arguments in the response filed on \_\_\_\_\_ under 37 C.F.R. § 1.116.

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01 FC:1001 770.00 DA

02 FC:1251 110.00 DA